

| | Type | L # | Hits | Search Text | DBs | Time Stamp | Cor ro mm en ts | De ni ti on | Er ro rs |
|---|------|-----|------|---|---|---------------------|-----------------------------|----------------------|----------------|
| 1 | BRS | L1 | 21 | duv with \$5resist and \$5lithography and low adj k adj dielectric and (silicon adj oxycarbide or sioc) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 01:09 | | | |
| 2 | BRS | L2 | 18 | ("5300460" "5530581" "5661093" "5804259" "5926740" "6054379" "6159871" "6284149" "6303523").PN. OR ("6372661").URPN. | US-PGPUB; USPAT; USOCR | 2005/09/19 01:06 | | | |
| 3 | BRS | L3 | 5 | duv with \$5resist and \$5lithography and low adj k adj dielectric and (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 01:11 | | | |
| 4 | BRS | L4 | 7 | duv with \$5resist and low adj k adj dielectric and (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:06 | | | |

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| 5 | BRS | L5 | 0 | duv and low adj k adj dielectric and (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) with (hydrogen or h2) with (treat\$5 or plasma) | | | | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:10 | | | |
| 6 | BRS | L6 | 0 | duv and dielectric and (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) with (hydrogen or h2) with (treat\$5 or plasma) | | | | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:11 | | | |
| 7 | BRS | L7 | 0 | (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) with (hydrogen or h2) with (treat\$5 or plasma) | | | | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:09 | | | |
| 8 | BRS | L8 | 10 | (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) with (hydrogen or h2) | | | | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:09 | | | |

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| Type | L # | Hits | | | | | | | |
| 9 | BRS | L9 | 4 | duv and low adj k adj dielectric and (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) with (hydrogen or h2) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:11 | | | |
| 10 | BRS | L10 | 4 | duv and (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) with (hydrogen or h2) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:11 | | | |
| 11 | BRS | L11 | 2 | duv and dielectric and (silicon adj oxycarbide or sioc) with (hydrogen or h2) with (treat\$5 or plasma) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:12 | | | |
| 12 | BRS | L12 | 12 | duv and dielectric and (silicon adj oxycarbide or sioc) with (hydrogen or h2) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:41 | | | |
| 13 | BRS | L13 | 2 | (duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2)).clm. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:41 | | | |

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| 14 | BRS | L14 | 0 | | | | (438/597).ccls. and duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:42 | | | |
| 15 | BRS | L15 | 3 | | | | (438/637).ccls. and duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:43 | | | |
| 16 | BRS | L16 | 1 | | | | (438/636).ccls. and duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:43 | | | |
| 17 | BRS | L17 | 3 | | | | (438/780).ccls. and duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:44 | | | |
| 18 | BRS | L18 | 1 | | | | (438/952).ccls. and duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:44 | | | |
| 19 | BRS | L19 | 9 | | | | ("438"/\$).ccls. and duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:45 | | | |

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| 20 | BRS | L20 | 35 | ("438"/\$).ccls. and \$2uv and (silicon adj oxycarbide or sioc) with (hydrogen or h2) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/09/19 02:45 | | |